Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	2	"6681716".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/12 14:46
S2	1	("6681716").URPN.	USPAT	OR	ON	2005/03/29 14:39
S3	10	("4871580" | "4957062" | "5120568" | "5560779" | "6013155" | "6143078" | "6213049" | "6383953" | "6397776" | "6487986").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/29 14:52
S5	20111	non$1planar	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/29 14:53
S7	3	non$1planar with (plasma cvd) with orifice	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/29 15:03
S8	45	non$1planar with (plasma cvd) with gas	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/29 15:06
S12	9	(multiple plural$5 many) near4 (plasma cvd) with uniform and 427/569.ccls.	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/29 15:13
S13	45	schaepkens.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/04/07 15:26
S14	11	non$1planar adj (substrate base) with (plasma cvd)	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/29 15:36
S15	42	(round rigid non$1planar) adj (substrate base) with (plasma cvd)	US-PGPUB; USPAT; USOCR	OR	ON	2005/03/29 15:36
S16	18	(expand$5 near3 plasma (ETP)) with array	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/07 15:21
S17	9149	plasma with flow adj rate	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/07 15:21
S18	1084	plasma and reactant with flow adj rate	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/07 15:35

S19	22	(multiple many couple several) adj plasma and reactant with flow adj rate	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/07 15:25
S21	18	schaepkens.in. and flow adj rate	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/04/07 15:26
S22	8	plasma and reactant with different adj flow adj rate	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/11 12:23
S23	2	"6383953".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/07 15:35
S24	1	("6383953").URPN.	USPAT	OR	ON	2005/04/07 15:36
S26	1	non-planar with plasma with flow adj rate	USPAT	OR	ON	2005/04/07 15:37
S27	8	non-planar with plasma with flow adj rate	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2005/04/07 15:37
S28	10	("5157015" | "5345079" | "5368897" | "5403399" | "5648699" | "5709577" | "5955377" | "5977697" | "6156389" | "6329899").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/04/07 15:42
S29	16	plasma and reactant with different near6 flow adj rate	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/07 15:44
S30	6	flow adj rate with coat$3 with non$1plan$3	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/11 12:24
S31	2	"6397776".pn.	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/12 15:22
S32	134	curv$3 near3 (substrate base) with plasma	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/12 15:23
S33	5	curv$3 near3 (substrate base) with plasma with flow	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/12 15:26

S34	49	curv$3 near3 (substrate base) with plasma and gas near5 flow	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/12 15:47
S35	12	curv$3 near3 (substrate base) with (ETP expand$3 thermal) and gas near5 flow	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/12 15:46
S36	19	63-187619	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/12 15:46
S37	2	"63187619"	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/12 15:46
S38	307	curv$3 near3 (substrate base) and plasma and gas adj flow	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/12 15:49
S39	1	curv$3 near3 (substrate base) and ETP and gas adj flow	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/12 15:47
S40	228	curv$3 near3 (substrate base) and plasma and gas adj flow and uniform	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/12 16:09
S41	7	curv$3 near3 (substrate base) and plasma and (var$7 near4 gas adj flow and uniform)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/12 17:10
S42	13	reticle with (carbon adj dioxide "CO.sub.2")	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/12 17:11
S43	16	(ETP expand$3 adj thermal) with flow adj rate$3	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/21 12:46
S45	3549	118/723$.ccls. and plasma	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/21 12:46
S46	117	118/723$.ccls. and plurality adj plasma	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/21 12:46

S47	4	118/723$.ccls. and plurality adj plasma with flow adj rate	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/21 12:46
S48	63	118/723$.ccls. and plurality adj plasma and flow adj rate	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/21 12:49
S49	18	118/723$.ccls. and plurality adj plasma and flow adj rate with control$6	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	ON	2005/04/21 12:52